

Second metal layer charge loss in the LHCb VELO

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Cluster Finding Efficiency

- A key aspect of the VELO physics performance is the ability to efficiently find and reconstruct **clusters**.
- A cluster is defined as one or more adjacent silicon strips with charge above a particular threshold.
- **Cluster Finding Efficiency** (CFE) is therefore the percentage of tracks at a particular position in the sensor where a cluster is obtained at the track extrapolation point.
- Typically measured using regular dedicated scans, but can also be derived from physics data.

Drop in CFE

• With irradiation a significant decrease in CFE is observed, specifically in the outer radius regions of **downstream R-sensors**:





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R and phi sensors

• VELO sensors require both **routing lines** to carry the collected charge to the amplifier and a **first metal layer** to couple to the sensor strips



 R and phi sensors are read out differently with routing lines perpendicular and parallel to the strips respectively



Charge coupling in R sensors

• No measurable effect before irradiation



With irradiation
Gauss-Landau ADC
distribution develops a
secondary peak at low
values

 Signal induced in routing lines positioned above outer strips in R sensors

2D CFE map **before** irradiation

• Plot CFE vs x and y sensor position at **40 pb⁻¹**:



2D CFE map after irradiation

• Repeat at 600 pb⁻¹:



Routing line coverage

• Higher CFE located at gaps in routing line coverage:



Radial dependence

• CFE drop appears to depend on **radius**:



CFE vs radius for a single R sensor (30) colour coded by fluence

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Radial dependence

• However more important is **distance to routing line** and **distance to strip**:



CFE vs routing line distance for a single R sensor (30) colour coded by strip distance after 1.220 fb⁻¹

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Radial dependence

- CFE is lowest when close to a routing line and far from a strip
- At large R this is more likely to occur due to sensor geometry:



Bin yields for CFE as a function of routing line distance and strip distance for a single R sensor (30) for different radius regions

Fluence dependence

• With fluence all regions of the sensors are experiencing a gradual drop in CFE



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Fluence predictions

- With further fluence expect CFE drop to continue
- Extrapolate based on current trend



CFE vs fluence for a single R sensor (10) colour coded by radial position in the sensor



Fluence predictions

- Each sensor experiences **different fluences** in different regions due to *z* position in the VELO
- Expected magnitude of effect varies between 96% 98% at 2.4fb⁻¹



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Fluence predictions

- However this effect is also seen in phi sensors
- Effect **not attributed** to charge coupling with routing lines, possibly due to sensor not being fully depleted



CFE vs fluence for a single phi sensor (74) colour coded by radial position in the sensor

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Voltage dependence

• With irradiation inner regions of sensors are **type inverting** and require a larger voltage to become fully depleted



Voltage predictions

 In 2011 all sensors were at 150 V. Some sensors expected to require > 200 V in 2012 based on EDV extrapolations



Voltage predictions

- Extrapolate based on current trend
- If CFE varies with voltage as expected, it may drop to as low as 90% in the inner regions of the sensors which are crucial for tracking performance
- Sensor operation voltages in 2012 need to be carefully considered to minimise this effect
- Further study with an upcoming dedicated scan

Outlook

- Clear evidence of charge loss to the routing lines in VELO R sensors
- Currently physics performance is unaffected (< 0.5%)
- Expected CFE to drop with further fluence and increased operation voltage
- Continue to investigate effect to best determine 2012 sensor voltages
- Also possible to change **clustering thresholds**

Backup

• Others are also studying double metal effects:

Novel Punch Through Protection (PTP)

PTP structures protect the AC coupling capacitors from large induced current caused by beam splash by routing the current to the bias ring. **measurement**

BZ4D-1

measure resistance between bias ring and DC pad by applying Vtest up to -150 V

PTP structure

p-bulk, 320µm thick test sensor Bias ring Al width extension:

- 1 : No extension, No p-stop
- 2 : Up to p-stop
- 3 : No extension
- 4 : Over p-stop
- 5 : Full extension





non irrad

n⁺ implant



 Potential input to future VELO simulation - work in progress